



IPW

DOCKET: FIS9-2003-0423-US1

PATENT

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

INVENTOR: Christopher P. Ausschnitt ) EXAMINER:  
SERIAL NO.: 10/771,684 ) ART UNIT: 2121  
FILING DATE: February 3, 2004 ) DATE: May 11, 2004  
FOR: Method of Patterning Process )  
Metrology Based on the Intrinsic )  
Focus Offset )

**REQUEST FOR CORRECTION OF FILING RECEIPT**

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Dear Sir:

We are in receipt of a Filing Receipt for the above identified application which contains an error.

**TITLE**

In the title please delete -- intrinis -- and substitute therefor -- intrinsic --.

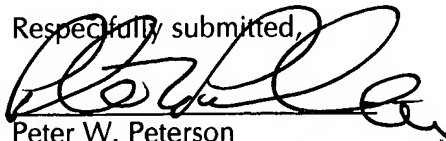
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**DeLIO & PETERSON, LLC**  
121 Whitney Avenue  
New Haven, CT 06510-1241  
(203) 787-0595

Respectfully submitted,

  
Peter W. Peterson  
Reg. No. 31,867

**CERTIFICATE OF MAILING**

I hereby certify that this correspondence is being deposited with the United States Postal Service on the date indicated below as first class mail in an envelope addressed to Mail Stop \_\_\_\_\_, Commissioner for Patents, P.O. 1450, Alexandria, VA 22313-1450.

Name: Marsha Speranza Date: May 11, 2004 Signature: Marsha H. Speranza



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APPL NO.	FILING OR 371 (c) DATE	ART UNIT	FIL FEE REC'D	ATTY. DOCKET NO	DRAWINGS	TOT CLMS	IND CLMS
10/771,684	02/03/2004	2121	770	FIS920030423US1	7	20	2

29505  
 DELIO & PETERSON, LLC  
 121 WHITNEY AVENUE  
 NEW HAVEN, CT 06510

CONFIRMATION NO. 4817

## FILING RECEIPT



\*OC000000012535317\*

FILE F-421  
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## Applicant(s)

Christopher P. Ausschnitt, Lexington, MA; ✓

## Assignment For Published Patent Application

International Business Machines Corporation, Amonk, NY;

## Domestic Priority data as claimed by applicant

## Foreign Applications

If Required, Foreign Filing License Granted: 05/05/2004

Projected Publication Date: 08/04/2005

Non-Publication Request: No

Early Publication Request: No

## Title

Method of patterning process metrology based on the intrinsic focus offset

## Preliminary Class

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Title 37, Code of Federal Regulations, 5.11 & 5.15**

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